

A CONTROLLED PROCESS AND RESULTING DEVICE

ABSTRACT OF THE DISCLOSURE

A technique for forming a film of material (12) from a donor substrate

- 5 (10). The technique has a step of introducing energetic particles (22) through a surface of a donor substrate (10) to a selected depth (20) underneath the surface, where the particles have a relatively high concentration to define a donor substrate material (12) above the selected depth. An energy source is directed to a selected region of the donor substrate to initiate a controlled cleaving action of the substrate
- 10 (10) at the selected depth (20), whereupon the cleaving action provides an expanding cleave front to free the donor material from a remaining portion of the donor substrate.